

Electronic Supplementary Information For
Stereomask Lithography (SML): Universal Multi-Object Micro-Patterning Technique for Biological Applications

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A testing alignment structure comprising micro pillars of 250 μ m in diameter on substrate plugging into a stereomask with micro holes of 300 μ m in diameter. The vernier structures indicate the misalignment in both horizontal and vertical directions is within 10 μ m. The scale bar shows 300 μ m.

